

Hazem Mesilhy

Engineer



About me

Passionate engineer specializing in computational lithography, focusing on EUV mask absorber and reflective multilayer modeling. Skilled in diverse programming languages and disciplines. Committed to pushing technological boundaries and finding innovative solutions. Proven track record of exceeding project goals. Eager to contribute to groundbreaking advancements in lithography and beyond.

personal

Hazem Mesilhy
nationality: Egyptian
1993

Areas of specialization

Computational Lithography
• Modeling • Programming
• Machine learning


Interests

Programming languages.
Mountain biking.

Skills

Numerical Optimization
/ Machine Learning / Optics
simulation and modeling
Linux / Problem solving
/ Teamwork


 hazem-mesilhy

 hazemiii

SHORT RESUMÉ

2019–Present

Research Scientist


ERLANGEN · Germany 

 Fraunhofer

Specialize in EUV lithography with a focus on mask/shadowing effects, EUV mask enhancement, absorber, and reflective multilayer modeling. Developed a reliable multilayer degradation model. Participated in European project management, student mentoring, customer presentations, and Dr.LiTHO maintenance.

2017–2019

Research Assistant


ERLANGEN · Germany 

 Fraunhofer

Engaged in first investigations into Hyper-NA EUV (NA of 0.75) feasibility study, while also providing vital support for EUV mask simulations and optimizations across diverse European projects. Participated in debugging, building, and generating installer packages for Dr.LiTHO to ensure smooth customer experiences.

June–Sept. 2015

Intern Programmer

JAIPUR · India 

 W Tweak

Focused on Android development, animation, and widget creation, incorporating machine learning algorithms for efficient unused folder management. Participation in DevOps and the software development cycle, contributing to streamlined server and proxy setup. Customized Chromium and Mozilla browsers for Android using C under Linux environment. Implemented image quality enhancements and filters with OpenCV.

DEGREES

2023 **Ph.D.**

FAU · Erlangen 

 FAU
FRIEDRICH-ALEXANDER-UNIVERSITÄT
ERLANGEN-NÜRNBERG

2019

Master of Science


FAU · Erlangen 

 FAU
FRIEDRICH-ALEXANDER-UNIVERSITÄT
ERLANGEN-NÜRNBERG

2016

Bachelor

FACULTY OF ENGINEERING ·
Cairo uni 

 Department of Electronics and
Electrical Communications Engineering
Faculty of Engineering - Cairo University

PROGRAMMING

python



C++



java



HPC



AWARDS

2021

Best Student Paper Award:
2021 SPIE Photomask Technology + EUV Lithography

LANGUAGES

Arabic
English
German

C2	mother tongue
C2	• • • • •
A2	• • • • •

PUBLICATIONS

More than 17 publications: Google Scholar

TALKS

Various SPIE conferences and panels.
2022 ASML Technology Conference
2023 ASML Technology Conference

Hazem Mesilhy  Erlangen  Germany  +49 176 3018 8018
 Hazem.Mesilhy@gmail.com